

Communication

Anisotropic Quantum Well Electro-Optics in Few-Layer Black Phosphorus

Michelle C. Sherrott, William S. Whitney, Deep Jariwala, Souvik Biswas,
Cora Went, Joeson Wong, George R. Rossman, and Harry A Atwater

Nano Lett., **Just Accepted Manuscript** • Publication Date (Web): 07 Dec 2018

Downloaded from <http://pubs.acs.org> on December 7, 2018

Just Accepted

“Just Accepted” manuscripts have been peer-reviewed and accepted for publication. They are posted online prior to technical editing, formatting for publication and author proofing. The American Chemical Society provides “Just Accepted” as a service to the research community to expedite the dissemination of scientific material as soon as possible after acceptance. “Just Accepted” manuscripts appear in full in PDF format accompanied by an HTML abstract. “Just Accepted” manuscripts have been fully peer reviewed, but should not be considered the official version of record. They are citable by the Digital Object Identifier (DOI®). “Just Accepted” is an optional service offered to authors. Therefore, the “Just Accepted” Web site may not include all articles that will be published in the journal. After a manuscript is technically edited and formatted, it will be removed from the “Just Accepted” Web site and published as an ASAP article. Note that technical editing may introduce minor changes to the manuscript text and/or graphics which could affect content, and all legal disclaimers and ethical guidelines that apply to the journal pertain. ACS cannot be held responsible for errors or consequences arising from the use of information contained in these “Just Accepted” manuscripts.



Anisotropic Quantum Well Electro-Optics in Few-Layer Black Phosphorus

Michelle C. Sherrott^{1,2,†}, William S. Whitney^{3,†}, Deep Jariwala^{1,2,^}, Souvik Biswas¹, Cora M. Went^{2,3}, Joeson Wong¹, George R. Rossman^{5,4}, Harry A. Atwater^{*1,2,5}

1. Thomas J. Watson Laboratory of Applied Physics, California Institute of Technology, Pasadena, CA 91125, USA

2. Resnick Sustainability Institute, California Institute of Technology, Pasadena, CA 91125, USA

3. Department of Physics, California Institute of Technology, Pasadena, CA 91125, USA

4. Division of Geological and Planetary Sciences, California Institute of Technology, Pasadena, CA 91125, USA

5. Joint Center for Artificial Photosynthesis, California Institute of Technology, Pasadena, CA 91125, USA

† Equal contributors

^ Current affiliation, Department of Electrical and Systems Engineering, University of Pennsylvania, Philadelphia, PA, 19104, USA

*Corresponding author: Harry A. Atwater (haa@caltech.edu)

Abstract

The incorporation of electrically tunable materials into photonic structures such as waveguides and metasurfaces enables dynamic, electrical control of light propagation at the nanoscale. Few-layer black phosphorus is a promising material for these applications due to its in-plane anisotropic, quantum well band structure, with a direct band gap that can be tuned from 0.3 eV to 2 eV with number of layers and subbands that manifest as additional optical transitions across a wide range of energies. In this work, we report an experimental investigation of three different, anisotropic electro-optic mechanisms that allow electrical control of the complex refractive index in few-layer black phosphorus from the mid-infrared to the visible: Pauli-blocking of intersubband optical transitions (the Burstein-Moss effect); the quantum-confined Stark effect; and the modification of quantum well selection rules by a symmetry-breaking, applied electric field. These effects generate near-unity tuning of the BP oscillator strength for some material thicknesses and photon energies, along a single in-plane crystal axis, transforming absorption from highly anisotropic to nearly isotropic. Lastly, the anisotropy of these electro-optical phenomena results in dynamic control of linear dichroism and

1
2
3 birefringence, a promising concept for active control of the complex polarization state of light,
4 or propagation direction of surface waves.
5
6
7

8 **Keywords:** Electro-optic tunability, black phosphorus, broadband, anisotropy, van der Waals
9 materials
10
11
12
13

14 Dynamic control of the near and far-field propagation of light is critical for next-generation
15 optoelectronic devices. Ultra-thin, layered materials are promising building blocks for this
16 functionality, as they are easily incorporated into atom-scale structures, and their optical
17 properties can be changed dramatically under applied electric fields^{1,2}. Few-layer black
18 phosphorus (BP) is particularly compelling due to its high electronic mobility, in-plane
19 anisotropy, and thickness-tunable quantum well band structure, with a direct band gap that
20 varies from 0.3 eV in bulk to 2 eV for monolayers^{3,4}. Recent work using electrostatic gating and
21 potassium ions has further shown that the electronic band gap of BP may be tuned by an
22 electric field⁵⁻⁸. These unique attributes have already enabled the realization of novel and high-
23 performance optoelectronic devices, including waveguide-integrated photodetectors⁹⁻¹³.
24
25
26
27
28
29
30
31
32
33

34 One of the most unusual features of BP is its large in-plane structural anisotropy, which
35 generates to a polarization-dependent optical response¹⁴⁻¹⁶ as well as mechanical¹⁷, thermal¹⁸,
36 and electrical transport characteristics^{19,20} that vary with in-plane crystallographic orientation²¹.
37 This optical anisotropy corresponds to a large, broadband birefringence²², wherein the distinct
38 optical index of refraction along each axis leads to a phase delay between polarization states of
39 light. Moreover, mirror-symmetry in the x-z plane forbids intersubband optical transitions along
40 the zigzag axis, and as a result, BP exhibits significant linear dichroism, wherein the material
41 absorption depends strongly on the polarization state of exciting light^{15,23}. An additional
42 constraint on optical absorption corresponds to the naturally occurring quantum well nature of
43 the BP band structure, wherein optical transitions are only allowed between subbands of
44 opposite parities, because photons carry parity -1. For low energy transitions, this corresponds
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60

1
2
3 to transitions between bands of equal quantum number (ie: v_1 to c_1 , v_2 to c_2), described in
4 depth in Ref [19].
5
6
7

8
9 In this work, we use multiple field-effect device configurations to isolate and characterize three
10 distinct, anisotropic electro-optic effects that allow significant control of the complex refractive
11 index in BP. These effects are Pauli-blocking of intersubband optical transitions, also known as a
12 Burstein-Moss or band-filling effect; the quantum confined Stark effect; and, modification of
13 quantum well selection rules by a symmetry-breaking electric field. The resulting response
14 approaches near-unity tunability of the BP oscillator strength for some BP thicknesses and
15 photon energies. Further, this tuning is only along one in-plane crystal axis (the armchair
16 direction). As a result, we are able to electrically control dichroism and birefringence in BP. In
17 some cases, we observe tuning of the black phosphorus optical response from highly
18 anisotropic to nearly isotropic. We observe this anisotropic tunability from the visible to mid-
19 infrared (mid-IR) spectral regimes, behavior not seen in traditional electro-optic materials such
20 as graphene²⁴, transparent conducting oxides^{25,26}, silicon²⁷, and quantum wells²⁸. This opens up
21 the possibility of realizing novel photonic structures in which linear dichroism in the van der
22 Waals plane can be continuously tuned with low power consumption, because the switching is
23 electrostatic in nature. By controlling optical losses in the propagation plane, for example,
24 efficient in-plane beam steering of surface plasmon polaritons or other guided modes is
25 enabled. Moreover, an electrically tunable polarizer could be realized by modulating the
26 polarization state of light absorbed in a resonant structure containing BP. Because this
27 tunability is strongest at infrared wavelengths, it could also enable control of the polarization
28 state of thermal radiation²⁹⁻³¹.
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46

47 In order to probe and distinguish the electro-optical tuning mechanisms evident in few-layer
48 BP, we used a combination of gating schemes wherein the BP either floats electrically in an
49 applied field or is contacted, as shown in Fig. 1a and described further in the Methods section.
50 We note that for all experiments, the samples are exfoliated on an oxide surface and
51 encapsulated in Al_2O_3 ; therefore, while strain effects are known to influence the band gap of 2D
52
53
54
55
56
57
58
59
60

1
2
3 materials^{32–34}, including few-layer BP, these are identical for all measurements. Polarization-
4 dependent optical measurements are taken aligned to the crystal axes, in order to probe the
5 structural anisotropy shown in Fig. 1b. This enables us to isolate the contribution of charge-
6 carrier density effects – i.e. a Burstein-Moss shift – and external field-effects – i.e.: the
7 quantum-confined Stark effect and control of forbidden transitions in the infrared – to the
8 tunability of linear dichroism, qualitatively illustrated in Figures 1c and 1d^{35–38}. In the
9 anisotropic Burstein-Moss (BM) shift, the optical band gap of the material is changed as a result
10 of band filling and the consequent Pauli-blocking of intersubband transitions. As the carrier
11 concentration of the sample is changed, the Fermi level moves into (out of) the conduction or
12 valence band, resulting in a decrease (increase) of absorptivity due to the disallowing (allowing)
13 of optical transitions^{39,40}. Because intersubband optical transitions are only allowed along the
14 armchair axis of BP^{15,21,41}, this tunability occurs only for light polarized along this axis. In the
15 quantum-confined Stark Effect, the presence of a strong electric field results in the leaking of
16 electron and hole wave functions into the band gap as Airy functions, red-shifting the
17 intersubband transitions energies⁴². In quantum well structures, this red-shifting is manifested
18 for multiple subbands, and therefore can be observed over a wide range of energies above the
19 band gap. To assess the gate-tunable anisotropy of the optical response of BP, the armchair and
20 zigzag axes, illustrated in Fig. 1b, of the samples considered are identified by a combination of
21 cross-polarized visible microscopy, described in the Supporting Information S1, and either
22 polarization-dependent Raman spectroscopy or infrared measurements. We perform
23 polarization-dependent Raman spectroscopy with the 532 nm excitation laser polarized parallel
24 to one of the two crystal axes as determined by cross-polarized visible microscopy. The
25 armchair and zigzag axes cannot be distinguished from the intensity of any of the Raman peaks
26 alone, as the polarization behavior of each peak depends strongly on the excitation wavelength
27 and the flake thickness⁴³. However, for 532 nm excitation and all thicknesses, the ratio of the
28 intensities of the A²g and the A¹g Raman peaks is higher for the armchair than the zigzag axis, so
29 this ratio remains a robust way to distinguish between the axes^{43,44}. Representative Raman
30 spectra are presented for the visible frequency sample on SrTiO₃ in Figure 1e.
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60

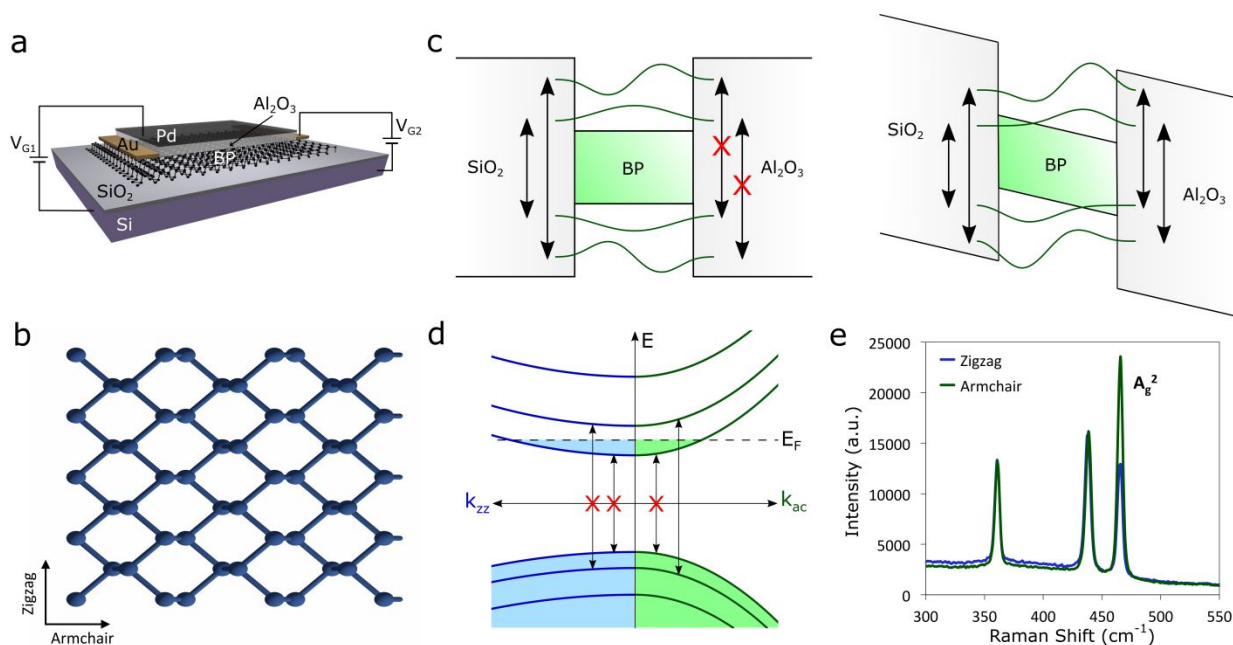


Figure 1. Anisotropic electro-optical effects in few-layer BP. (a) Schematic figure of infrared tunability devices. Few-layer BP is mechanically exfoliated on 285 nm SiO₂/Si and then capped with 45 nm Al₂O₃ by ALD. A semitransparent top contact of 5 nm Pd is used to apply field (V_{G1}) while the device floats and 20 nm Ni/200 nm Au contacts are used to gate (V_{G2}) the contacted device. (b) Crystal structure of BP with armchair (AC) and zigzag (ZZ) axes indicated. (c) Illustration of two field-driven electro-optical effects: the quantum-confined Stark effect, and symmetry-breaking modification of quantum well selection rules. In the quantum-confined Stark effect, an external field tilts the quantum well energy levels, causing a red-shifting of the intersubband transition energies. In the observed modification of selection rules, this field breaks the symmetry of the quantum well and orthogonality of its wavefunctions, allowing previously forbidden transitions to occur (eg: from v_1 to c_2 , a previously disallowed transition). (d) Illustration of anisotropic Pauli-blocking (Burstein-Moss effect) in BP. Intersubband transitions are blocked due to the filling of the conduction band. Along the ZZ axis, all optical transitions are disallowed regardless of carrier concentration. (e) Raman spectra with excitation laser polarized along AC and ZZ axes. The intensity ratio between the A_g^2 peak and the A_g^1 peak is used to identify crystal axes.

To illustrate the mechanisms of tunable dichroism of BP in the mid-infrared, we measure tunability of transmittance using Fourier-Transform Infrared (FTIR) microscopy as a function of externally (V_{G1}) or directly applied bias (V_{G2}), presented for a 3.5 nm thick flake, as determined from atomic force microscopy (AFM) (Figure S1, Supporting Information), in Figure 2. Fig. 2b

presents the raw extinction of the flake along the armchair axis at zero bias, obtained by normalizing the armchair axis extinction to that of the optically inactive zigzag axis. A band edge of approximately 0.53 eV is measured, consistent with a thickness of 3.5 nm. A broad, weak shoulder feature is observed at approximately 0.75 eV. The corresponding calculated optical constants for the flake are presented in Figure 2c for comparison. A Kubo formula approach is used for this calculation, as is described in further detail under Calculations in the Methods section, and in Ref [35–37].

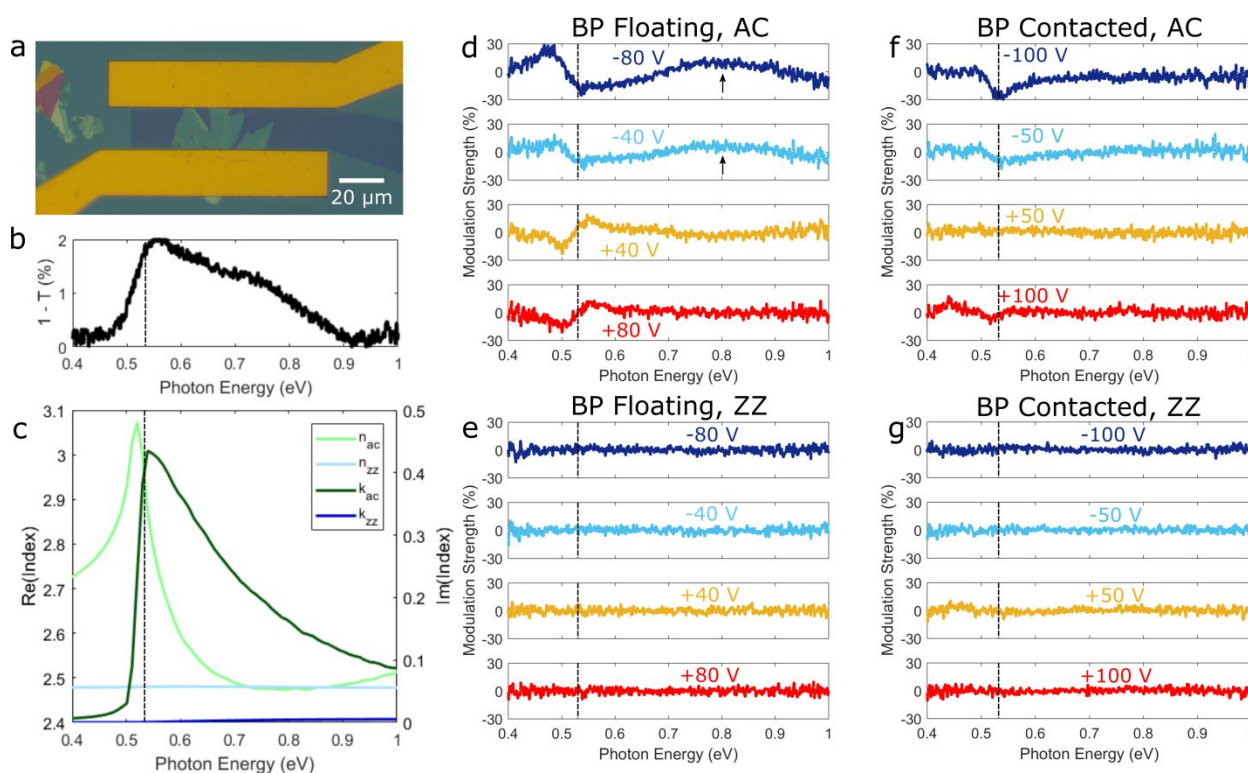


Figure 2. Electrically tunable linear dichroism: quantum-confined Stark and Burstein-Moss effects and forbidden transitions. (a) Optical image of fabricated sample with two Au contact pads for direct electrical contact to the BP and a semi-transparent Pd top contact between them, separated from the BP by a thin layer of Al_2O_3 , as in the schematic of Figure 1a; (b) Zero-bias infrared extinction of 3.5 nm flake, polarized along armchair (AC) axis. (c) Calculated index of refraction for 3.5 nm thick BP with a Fermi energy at mid-gap. (d) Tunability of BP oscillator strength with field applied to floating device, for light polarized along the AC axis. (e) Corresponding tunability for light polarized along the zigzag (ZZ) axis. (f) Tunability of BP oscillator strength with gating of contacted device, for light polarized along the AC axis. (g) Corresponding tunability for light polarized along the ZZ axis.

Figures 2d and 2e illustrate the influence of an external field on the extinction of BP with carrier concentration held constant (i.e. the BP is left floating). The extinction data for each voltage is normalized to the zero bias case and to the peak BP extinction seen in Figure 2b, to obtain a tuning strength percentage that quantifies the observed tunability of the BP oscillator strength. In total, this tuning strength percentage at voltage V' is defined as follows.

$$\text{Modulation Strength (\%)} = 100 \times \frac{-\Delta T_{V'/0V} (\%)}{\max(-\Delta T_{AC/ZZ}) (\%)} \quad (1)$$

$$\text{where: } -\Delta T_{A/B} (\%) = 100 \times \left(1 - \frac{T_A}{T_B}\right)$$

As an example, for the device examined in Fig. 2, the maximum value of $-\Delta T_{AC/ZZ}$ is shown in Fig. 2b to be approximately 2 percent. At its strongest, $-\Delta T_{V'/0V}$ approaches (for -80 V applied, and a photon energy of 0.475 eV) about one third of this 2 percent maximal BP extinction value, yielding a modulation strength of 30%. We note that this normalization scheme underestimates the tuning strength for photon energies where overall BP extinction is lower, such as away from any subband edges. Along the armchair axis, presented in Fig. 2d, two tunable features are measured near photon energies of 0.5 and 0.8 eV. We explain the first feature at 0.5 eV as arising from a shifting of the BP band edge due to the quantum-confined Stark effect. At negative bias, the band gap effectively shrinks and this is manifest as a redistribution of oscillator strength near the band edge to lower energies. As a result, an increase in absorptance is measured below the zero-bias optical band gap, and a decrease is seen above it. At positive bias, this trend is weakened and reversed. We propose two explanations for this asymmetry: the first is the influence of electrical hysteresis, and the second is the presence of a small internal field in the BP at zero bias, which has been observed in previous works on the infrared optical response of few-layer BP¹⁵.

The second, higher energy feature observed in the measured spectrum does not correspond to any predicted intersubband transition. Rather, we propose it arises due to the modification of quantum well selection rules that limit the allowed intersubband optical transitions in black phosphorus by the applied electric field. In a symmetric quantum well, only transitions between states with equal quantum numbers are allowed, as other states have orthogonal

1
2
3 wavefunctions with zero overlap integrals³⁶. However, a strong applied field breaks the
4 symmetry of the quantum well and the orthogonality of its wavefunctions, eliminating this
5 selection rule. We can likely assign this new feature to the first hybrid transition, E_{12} , consistent
6 with literature results for a flake of the same thickness (6-layers) and zero-bias band gap
7 energy¹⁵. Due to some uncertainty in flake thickness, this feature could also be well-explained
8 by a combination of the first two hybrid transitions for a 7-layer sample. We note that this
9 feature is present in the 0 V extinction spectrum, consistent with a zero-bias internal field. As
10 the symmetry is further broken with an externally-applied electric field, this transition is
11 strengthened. Under positive bias, the internal and external fields are in competition, resulting
12 in minimal change. This suppressed tunability can also be attributed to hysteresis, as before.
13
14
15
16
17
18
19
20
21
22

23 In Figure 2e, no tunability is measured for any applied bias for light polarized along the zigzag
24 axis. This can be well understood due to the dependence of the Stark effect on the initial
25 oscillator strength of an optical transition; because no inter-subband optical transitions are
26 allowed along this axis, the field effect is weak. Similar behavior has been observed in excitons
27 in ReS_2 based on an optical Stark effect⁴⁵. Moreover, while the externally applied field can allow
28 'forbidden' transitions along the armchair axis by breaking the out-of-plane symmetry of the
29 quantum well, in-plane symmetry properties and thus the selection rule precluding all zig-zag
30 axis inter-subband transitions are unaffected. This selection rule and the corresponding
31 symmetry properties have been previously described¹⁹.
32
33
34
35
36
37
38
39
40
41

42 In Figures 2f and 2g, we present the complementary data set of tunable dichroism
43 measurements due to a directly applied gate bias with electrical contact made to the BP in a
44 standard field-effect transistor (FET) geometry. Here, we observe tunability dominated by
45 carrier concentration effects. At the band gap energy of approximately 0.53 eV, a simple
46 decrease in absorptance is observed at negative and large positive biases, consistent with an
47 ambipolar BM shift. Unlike the results of applying field while the BP floats, no tunability of the
48 forbidden transition at 0.75 eV is observed; this is explained in part due to the screening of the
49 electric field due to the carrier concentration tunability. We additionally may consider the
50
51
52
53
54
55
56
57
58
59
60

1
2
3 possibility that this optical transition is disallowed by Pauli-blocking effects, negating the
4 symmetry-breaking effect of the directly applied field. As in the case for the floating BP
5 measurement, no tunability is observed along the zigzag axis.
6
7
8
9

10 The anisotropic electro-optical effects described above change character rapidly as the BP
11 thickness – and hence band gap and band structure – is varied. Figure 3 presents analogous
12 results on a flake of 8.5 nm thickness, determined by AFM (see Supporting Information, Fig. S1),
13 for which an optical image is presented in Fig. 3a. Due to the increased thickness, the energy
14 separation between subbands is smaller, resulting in a narrower free-spectral range between
15 absorptance features measured in the zero-bias spectrum, presented in Fig. 3b and for which
16 corresponding calculated optical constants are presented in Fig. 3c. Results for tunability by an
17 external field with the BP left floating are presented in Fig. 3d. As in the thin flake, substantial
18 tuning of the absorptance at each intersubband transition is observed due to the quantum-
19 confined Stark effect (QCSE) red-shifting the energy of the subbands. Due to the large Stark
20 coefficient in BP – which increases with thickness in the few-layer limit – absorption is nearly
21 100% suppressed, resulting in an approximately isotropic optical response from the material^{6,46}.
22 Unlike the previous sample, tuning of forbidden transitions is not apparent; all features
23 correspond to transitions measured in the 0 V normalization scheme as well as the calculated
24 optical constants for a thickness of 8.5 nm. As before, no tuning is seen along the zigzag axis, as
25 shown in Figure S2, Supporting Information. In Fig. 3e, the tunability for directly gated,
26 contacted BP is shown. The observed tuning – a reduction in extinction centered at each of the
27 calculated intersubband transition energies – is relatively weak and does not persist to high
28 photon energies. This suggests that the dominant tunability mechanism is the ambipolar BM
29 shift, rather than the QCSE. Additional measurements at lower energies are presented in Figure
30 S3, Supporting Information.
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60

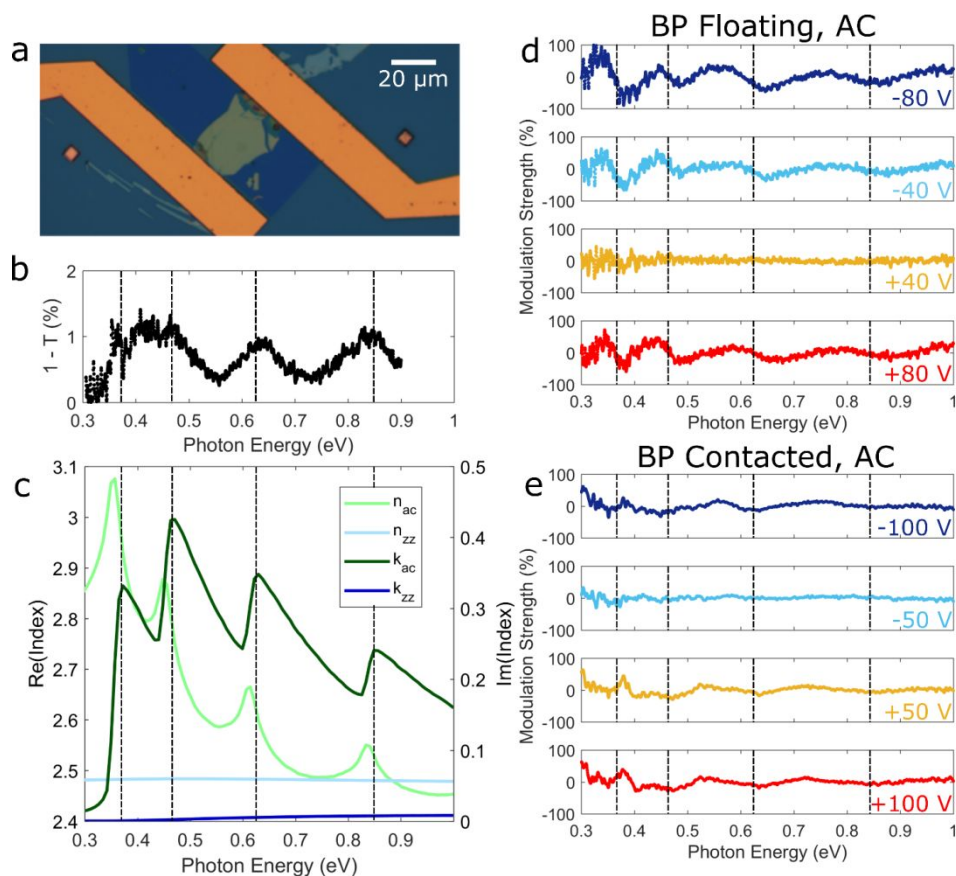


Figure 3. Variation of Tunability with BP Thickness. (a) Optical image of fabricated 8.5 nm sample. (b) Zero-bias extinction of 8.5 nm flake, polarized along AC axis. (c) Calculated index of refraction for 8.5 nm thick BP. (d) Tuning of BP oscillator strength with field applied to floating device, for light polarized along the AC axis. (e) Tuning of BP oscillator strength with gating of contacted device, for light polarized along the AC axis.

In Figure 4 we present results of gate-tunable dichroism at visible frequencies in a 20 nm thick flake. A new device geometry is used to enable transmission of visible light, shown schematically in Fig. 4a and in an optical image in Fig. 4b. In this configuration, a SrTiO₃ substrate is utilized to allow transmission-mode measurements at visible wavelengths. A symmetric gating scheme is devised based on semi-transparent top and back gate electrodes of 5 nm Ni, as described in the Methods section. Only an applied field, floating BP measurement is utilized, as band-filling effects should be negligible at this energy range. In Fig. 4c, we present tunability results from 1.3 to 2 eV. Due to the QCSE, tunability is observed up to 1.8 eV, corresponding to red light. Thus we demonstrate that electro-optic tuning of linear dichroism is

possible across an extraordinarily wide range of wavelengths in a single material system, enabling multifunctional photonic devices with broadband operation.

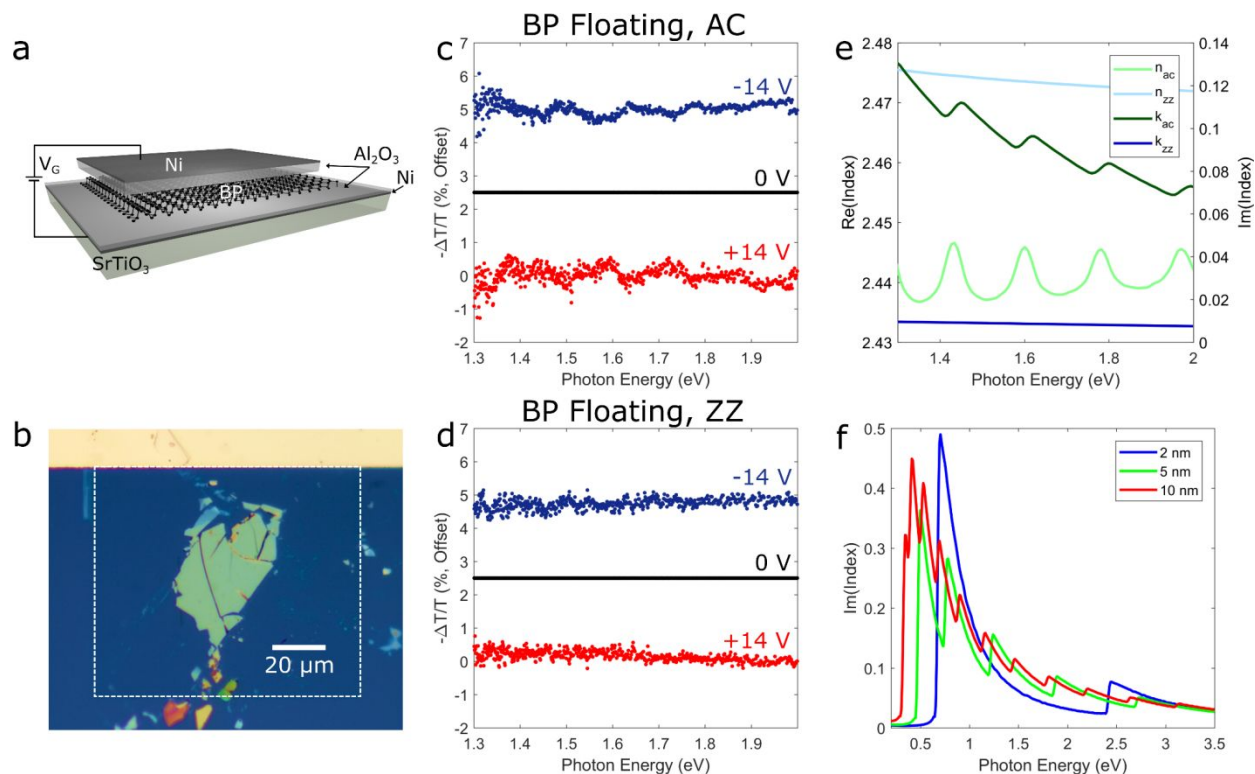


Figure 4. Tunability in the Visible. (a) Schematic figure of visible tuning device. Few-layer BP is mechanically exfoliated on 45 nm Al_2O_3 /5 nm Ni on SrTiO_3 and then coated with 45 nm Al_2O_3 . A 5 nm thick semitransparent Ni top contact is used. (b) Optical image of fabricated sample with 20 nm thick BP. Dashed white line indicates the boundary of the top Ni contact. (c) Tuning of extinction with field applied to floating device, for light polarized along the AC axis. (d) Corresponding tuning for light polarized along the ZZ axis. (e) Calculated index of refraction for 20 nm thick BP for the measured energies. (f) Calculated imaginary index of refraction of several thicknesses of BP from the infrared to visible.

The decay of BP intersubband oscillator strength at higher photon energies provides a spectral cutoff for QCSE-based tunability, but for 5 nm BP or thinner this oscillator strength is strong through the entire visible regime, as illustrated in Fig. 4f. We thus suggest that in very thin BP, strong tuning of absorption and dichroism is possible to even higher energies. By selecting a flake of 2 nm, for example, tunable linear dichroism is possible up to 3 eV from the band gap energy of 0.75 eV. A higher density of features, beginning at lower energies, may be introduced by utilizing a thicker flake, with slightly decreased tuning strength, as seen for 5 and 10 nm

1
2
3 thickness flakes. We also note that by substituting graphene top and bottom contacts or
4 utilizing nanophotonic techniques to focus light in the BP, higher absolute tuning strength could
5 be easily realized.
6
7
8
9

10 This phenomenon is in stark contrast to the gate-tunability of the optical response of other 2D
11 materials, where substantial tunability is typically constrained to the narrowband energy of the
12 primary exciton, as in MoS₂ and WS₂^{1,47}. In another van der Waals materials system, monolayer
13 graphene, tunability is accessible over a broader wavelength range due to the Pauli-blocking of
14 optical transitions at $2E_F$; however, this is limited to the range over which electrostatic gating is
15 effective, typically between $E_F \sim 0$ to $E_F \sim 0.5$ eV^{2,48}. Moreover, these materials are not dichroic
16 or birefringent in-plane, and so BP offers a novel phenomenon that can be taken advantage of
17 to realize previously challenging or impossible photonic devices. The same restriction is true of
18 bulk tunable materials such as quantum wells, transparent conducting oxides, and transition
19 metal nitrides.
20
21
22
23
24
25
26
27
28
29

30 In summary, we have observed and isolated three competing, anisotropic electro-optical effects
31 in few-layer black phosphorus: the Pauli-blocking of intersubband transitions (Burstein-Moss
32 effect), the quantum-confined Stark effect, and the modification of quantum well selection
33 rules by a symmetry breaking electric field. These effects, which produce near unity changes in
34 the black phosphorus oscillator strength for some material thicknesses and photon energies,
35 can be tuned to a broad range of frequencies, from the mid infrared to the visible, by
36 controlling the thickness and thus band structure of the black phosphorus. Further, these are
37 strongly anisotropic electro-optical effects, and we thus observe them to allow electrical
38 control of both linear dichroism and birefringence. We observe that absorption in BP can be
39 tuned from anisotropic to nearly isotropic. We suggest that these phenomena and this material
40 are a promising platform for controlling the in-plane propagation of surface or waveguide
41 modes, as well as for polarization-switching, phase and amplitude control, and reconfigurable
42 far-field metasurfaces. As with van der Waals materials as a whole, few layer black phosphorus
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60

1
2
3 provides a route not only to an improved material platform for optoelectronics, but also to new
4 physics, and the potential new technology paradigms that follow.
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60

Methods

Infrared Sample Preparation:

Samples for infrared measurements were fabricated by mechanically exfoliating few-layer BP onto 285 nm SiO₂/Si in a glove box environment. Contacts of 20 nm Ni/200 nm Au were fabricated by electron beam lithography, electron beam evaporation, and liftoff. A top gate dielectric of 45 nm Al₂O₃ was deposited by atomic layer deposition (ALD) following the technique in Ref. ⁴⁹, and a semi-transparent top contact of 5 nm Ni was deposited by electron beam evaporation and liftoff. Measurements were performed in a Fourier Transform Infrared Spectrometer coupled to a microscope.

Visible Sample Preparation:

Samples for visible measurements were fabricated by depositing a 5 nm thick semi-transparent back contact of Ni, followed by 45 nm Al₂O₃ by ALD on a 0.5 mm thick SrTiO₃ substrate. Few-layer BP was then mechanically exfoliated and electrical contacts were fabricated as above. Measurements are performed in a visible spectrometer. Nickel was selected as the optimum metallic contact through Finite-Difference Time Domain simulations presented in Figure S4, Supporting Information.

Calculations:

Calculations of the optical constants of BP are based on the formalism developed in Ref. [36]. Optical conductivity σ is calculated using the Kubo formula within an effective low-energy Hamiltonian for different thicknesses. The permittivity is calculated as $\epsilon(\omega) = \epsilon_{\infty} + i\sigma/\omega\delta$ where δ is the thickness of the BP, and the high-frequency permittivity ϵ_{∞} is taken from Ref. [41].

Associated Content

Supporting Information Available: Identification of crystal axes, AFM characterization, additional sample spectra, visible sample substrate simulations, high modulation strength sample spectra, comparison to theory

Author Information

Corresponding Author: E-mail: haa@caltech.edu

ORCID

Michelle C. Sherrott: 0000-0002-7503-9714

Harry A. Atwater: 0000-0001-9435-0201

Author Contributions: M.C.S. and W.S.W. are equal contributors.

Notes: The authors declare no competing financial interest.

Acknowledgements:

The authors gratefully acknowledge support from the Department of Energy, Office of Science under Grant DE-FG02-07ER46405 and for facilities of the DOE “Light-Material Interactions in Energy Conversion” Energy Frontier Research Center (DE-SC0001293). W.S.W. also acknowledges support from an NDSEG Graduate Research Fellowship. M.C.S., D.J. and C.M.W. acknowledge fellowship support from the Resnick Institute. J.W. acknowledges support from the National Science Foundation Graduate Research Fellowship under grant no. 1144469.

References:

- (1) Mak, K. F.; He, K.; Lee, C.; Lee, G. H.; Hone, J.; Heinz, T. F.; Shan, J. Tightly Bound Trions in Monolayer MoS₂. *Nat. Mater.* **2013**, *12*, 207–211.
- (2) Fei, Z.; Rodin, A. S.; Andreev, G. O.; Bao, W.; McLeod, A. S.; Wagner, M.; Zhang, L. M.; Zhao, Z.; Thiemens, M.; Dominguez, G.; et al. Gate-Tuning of Graphene Plasmons Revealed by Infrared Nano-Imaging. *Nature* **2012**, *487*, 82–85.
- (3) Li, L.; Yu, Y.; Ye, G. J.; Ge, Q.; Ou, X.; Wu, H.; Feng, D.; Chen, X. H.; Zhang, Y. Black Phosphorus Field-Effect Transistors. *Nat. Nanotechnol.* **2014**, *9*, 372–377.
- (4) Ling, X.; Wang, H.; Huang, S.; Xia, F.; Dresselhaus, M. S. The Renaissance of Black Phosphorus. *Proc. Natl. Acad. Sci.* **2015**, *112*, 4523–4530.
- (5) Kim, J.; Baik, S. S.; Ryu, S. H.; Sohn, Y.; Park, S.; Park, B.-G.; Denlinger, J.; Yi, Y.; Choi, H. J.; Kim, K. S. Observation of Tunable Band Gap and Anisotropic Dirac Semimetal State in Black Phosphorus. *Science* **2015**, *349*, 723–726.
- (6) Liu, Y.; Qiu, Z.; Carvalho, A.; Bao, Y.; Xu, H.; Tan, S. J. R.; Liu, W.; Castro Neto, A. H.; Loh, K. P.; Lu, J. Gate-Tunable Giant Stark Effect in Few-Layer Black Phosphorus. *Nano Lett.* **2017**, *17*, 1970–1977.

- 1
2
3 (7) Deng, B.; Tran, V.; Xie, Y.; Jiang, H.; Li, C.; Guo, Q.; Wang, X.; Tian, H.; Koester, S. J.; Wang,
4 H.; et al. Efficient Electrical Control of Thin-Film Black Phosphorus Bandgap. *Nat.*
5 *Commun.* **2017**, 14474.
6
7 (8) Peng, R.; Khaliji, K.; Youngblood, N.; Grassi, R.; Low, T.; Li, M. Midinfrared Electro-Optic
8 Modulation in Few-Layer Black Phosphorus. *Nano Lett.* **2017**, *17*, 6315–6320.
9
10 (9) Youngblood, N.; Chen, C.; Koester, S. J.; Li, M. Waveguide-Integrated Black Phosphorus
11 Photodetector with High Responsivity and Low Dark Current. *Nat. Photonics* **2015**, *9*,
12 247–252.
13
14 (10) Wang, T.; Hu, S.; Chamlagain, B.; Hong, T.; Zhou, Z.; Weiss, S. M.; Xu, Y.-Q. Visualizing
15 Light Scattering in Silicon Waveguides with Black Phosphorus Photodetectors. *Adv.*
16 *Mater.* **2016**, *28*, 7162–7166.
17
18 (11) Chen, C.; Youngblood, N.; Li, M. Study of Black Phosphorus Anisotropy on Silicon
19 Photonic Waveguide. In *2015 Optoelectronics Global Conference (OGC)*; 2015; pp 1–3.
20
21 (12) Huang, M.; Wang, M.; Chen, C.; Ma, Z.; Li, X.; Han, J.; Wu, Y. Broadband Black-
22 Phosphorus Photodetectors with High Responsivity. *Adv. Mater.* **2016**, *28* (18),
23 3481–3485.
24
25 (13) Chen, C.; Youngblood, N.; Peng, R.; Yoo, D.; Mohr, D. A.; Johnson, T. W.; Oh, S.-H.; Li, M.
26 Three-Dimensional Integration of Black Phosphorus Photodetector with Silicon
27 Photonics and Nanoplasmonics. *Nano Lett.* **2017**, *17*, 985–991.
28
29 (14) Wang, X.; Jones, A. M.; Seyler, K. L.; Tran, V.; Jia, Y.; Zhao, H.; Wang, H.; Yang, L.; Xu, X.;
30 Xia, F. Highly Anisotropic and Robust Excitons in Monolayer Black Phosphorus. *Nat.*
31 *Nanotechnol.* **2015**, *10*, 517–521.
32
33 (15) Zhang, G.; Huang, S.; Chaves, A.; Song, C.; Özçelik, V. O.; Low, T.; Yan, H. Infrared
34 Fingerprints of Few-Layer Black Phosphorus. *Nat. Commun.* **2017**, *8*, 14071.
35
36 (16) Liu, Z.; Aydin, K. Localized Surface Plasmons in Nanostructured Monolayer Black
37 Phosphorus. *Nano Lett.* **2016**, *16*, 3457–3462.
38
39 (17) Wei, Q.; Peng, X. Superior Mechanical Flexibility of Phosphorene and Few-Layer Black
40 Phosphorus. *Appl. Phys. Lett.* **2014**, *104*, 251915.
41
42 (18) Luo, Z.; Maassen, J.; Deng, Y.; Du, Y.; Garrelts, R. P.; Lundstrom, M. S.; Ye, P. D.; Xu, X.
43 Anisotropic In-Plane Thermal Conductivity Observed in Few-Layer Black
44 Phosphorus. *Nat. Commun.* **2015**, 9572.
45
46 (19) Yuan, H.; Liu, X.; Afshinmanesh, F.; Li, W.; Xu, G.; Sun, J.; Lian, B.; Curto, A. G.; Ye, G.;
47 Hikita, Y.; et al. Polarization-Sensitive Broadband Photodetector Using a Black
48 Phosphorus Vertical p–n Junction. *Nat. Nanotechnol.* **2015**, *10*, 707–713.
49
50 (20) Liao, B.; Zhao, H.; Najafi, E.; Yan, X.; Tian, H.; Tice, J.; Minnich, A. J.; Wang, H.; Zewail, A.
51 H. Spatial-Temporal Imaging of Anisotropic Photocarrier Dynamics in Black
52 Phosphorus. *Nano Lett.* **2017**, *17*, 3675–3680.
53
54 (21) Xia, F.; Wang, H.; Jia, Y. Rediscovering Black Phosphorus as an Anisotropic Layered
55 Material for Optoelectronics and Electronics. *Nat. Commun.* **2014**, 5458.
56
57 (22) Lan, S.; Rodrigues, S.; Kang, L.; Cai, W. Visualizing Optical Phase Anisotropy in Black
58 Phosphorus. *ACS Photonics* **2016**, *3*, 1176–1181.
59
60 (23) Qiao, J.; Kong, X.; Hu, Z.-X.; Yang, F.; Ji, W. High-Mobility Transport Anisotropy and
Linear Dichroism in Few-Layer Black Phosphorus. *Nat. Commun.* **2014**, 5475.
(24) Sherrott, M. C.; Hon, P. W. C.; Fountaine, K. T.; Garcia, J. C.; Ponti, S. M.; Brar, V. W.;
Sweatlock, L. A.; Atwater, H. A. Experimental Demonstration of >230° Phase

- 1
2
3 Modulation in Gate-Tunable Graphene–Gold Reconfigurable Mid-Infrared
4 Metasurfaces. *Nano Lett.* **2017**, *17*, 3027–3034.
- 5 (25) Park, J.; Kang, J.-H.; Kim, S. J.; Liu, X.; Brongersma, M. L. Dynamic Reflection Phase and
6 Polarization Control in Metasurfaces. *Nano Lett.* **2017**, *17*, 407–413.
- 7 (26) Huang, Y.-W.; Lee, H. W. H.; Sokhoyan, R.; Pala, R. A.; Thyagarajan, K.; Han, S.; Tsai, D.
8 P.; Atwater, H. A. Gate-Tunable Conducting Oxide Metasurfaces. *Nano Lett.* **2016**, *16*,
9 5319–5325.
- 10 (27) Xu, Q.; Schmidt, B.; Pradhan, S.; Lipson, M. Micrometre-Scale Silicon Electro-Optic
11 Modulator. *Nature* **2005**, *435*, 325–327.
- 12 (28) Kuo, Y.-H.; Lee, Y. K.; Ge, Y.; Ren, S.; Roth, J. E.; Kamins, T. I.; Miller, D. A. B.; Harris, J. S.
13 Strong Quantum-Confined Stark Effect in Germanium Quantum-Well Structures on
14 Silicon. *Nature* **2005**, *437*, 1334–1336.
- 15 (29) Inoue, T.; Zoysa, M. D.; Asano, T.; Noda, S. Realization of Dynamic Thermal Emission
16 Control. *Nat. Mater.* **2014**, *13*, 928–931.
- 17 (30) Coppens, Z. J.; Valentine, J. G. Spatial and Temporal Modulation of Thermal Emission.
18 *Adv. Mater.* 201701275.
- 19 (31) Brar, V. W.; Sherrott, M. C.; Jang, M. S.; Kim, S.; Kim, L.; Choi, M.; Sweatlock, L. A.;
20 Atwater, H. A. Electronic Modulation of Infrared Radiation in Graphene Plasmonic
21 Resonators. *Nat. Commun.* **2015**, 7032.
- 22 (32) Rodin, A. S.; Carvalho, A.; Castro Neto, A. H. Strain-Induced Gap Modification in Black
23 Phosphorus. *Phys. Rev. Lett.* **2014**, *112*, 176801.
- 24 (33) Wang, X.; Tian, H.; Xie, W.; Shu, Y.; Mi, W.-T.; Ali Mohammad, M.; Xie, Q.-Y.; Yang, Y.;
25 Xu, J.-B.; Ren, T.-L. Observation of a Giant Two-Dimensional Band-Piezoelectric Effect
26 on Biaxial-Strained Graphene. *Npg Asia Mater.* **2015**, e154.
- 27 (34) Xu, K.; Wang, K.; Zhao, W.; Bao, W.; Liu, E.; Ren, Y.; Wang, M.; Fu, Y.; Zeng, J.; Li, Z.; et
28 al. The Positive Piezoconductive Effect in Graphene. *Nat. Commun.* **2015**, 8119.
- 29 (35) Whitney, W. S.; Sherrott, M. C.; Jariwala, D.; Lin, W.-H.; Bechtel, H. A.; Rossman, G. R.;
30 Atwater, H. A. Field Effect Optoelectronic Modulation of Quantum-Confined Carriers
31 in Black Phosphorus. *Nano Lett.* **2017**, *17*, 78–84.
- 32 (36) Low, T.; Rodin, A. S.; Carvalho, A.; Jiang, Y.; Wang, H.; Xia, F.; Castro Neto, A. H.
33 Tunable Optical Properties of Multilayer Black Phosphorus Thin Films. *Phys. Rev. B*
34 **2014**, *90*, 075434.
- 35 (37) Lin, C.; Grassi, R.; Low, T.; Helmy, A. S. Multilayer Black Phosphorus as a Versatile
36 Mid-Infrared Electro-Optic Material. *Nano Lett.* **2016**, *16*, 1683–1689.
- 37 (38) Deng, B.; Tran, V.; Xie, Y.; Jiang, H.; Li, C.; Guo, Q.; Wang, X.; Tian, H.; Koester, S. J.;
38 Wang, H.; et al. Efficient Electrical Control of Thin-Film Black Phosphorus Bandgap.
39 *Nat. Commun.* **2017**, 14474.
- 40 (39) Burstein, E. Anomalous Optical Absorption Limit in InSb. *Phys. Rev.* **1954**, *93*, 632–
41 633.
- 42 (40) Moss, T. S. Theory of the Spectral Distribution of Recombination Radiation from InSb.
43 *Proc. Phys. Soc. Sect. B* **1957**, *70*, 247.
- 44 (41) Wang, X.; Lan, S. Optical Properties of Black Phosphorus. *Adv. Opt. Photonics* **2016**, *8*,
45 618–655.
- 46 (42) Miller, D. A. B.; Chemla, D. S.; Damen, T. C.; Gossard, A. C.; Wiegmann, W.; Wood, T. H.;
47 Burrus, C. A. Band-Edge Electroabsorption in Quantum Well Structures: The
48 Quantum-Confined Stark Effect. *Phys. Rev. Lett.* **1984**, *53*, 2173–2176.
- 49
50
51
52
53
54
55
56
57
58
59
60

- 1
2
3
4
5
6
7
8
9
10
11
12
13
14
15
16
17
18
19
20
21
22
23
24
25
26
27
28
29
30
31
32
33
34
35
36
37
38
39
40
41
42
43
44
45
46
47
48
49
50
51
52
53
54
55
56
57
58
59
60
- (43) Ling, X.; Huang, S.; Hasdeo, E. H.; Liang, L.; Parkin, W. M.; Tatsumi, Y.; Nugraha, A. R. T.; Puretzky, A. A.; Das, P. M.; Sumpter, B. G.; et al. Anisotropic Electron-Photon and Electron-Phonon Interactions in Black Phosphorus. *Nano Lett.* **2016**, *16*, 2260–2267.
- (44) Hsiao, Y.; Chang, P.-Y.; Fan, K.-L.; Hsu, N.-C.; Lee, S.-C. Black Phosphorus with a Unique Rectangular Shape and Its Anisotropic Properties. *AIP Adv.* **2018**, *8*, 105216.
- (45) Sim, S.; Lee, D.; Noh, M.; Cha, S.; Soh, C. H.; Sung, J. H.; Jo, M.-H.; Choi, H. Selectively Tunable Optical Stark Effect of Anisotropic Excitons in Atomically Thin ReS₂. *Nat. Commun.* **2016**, 13569.
- (46) Dolui, K.; Quek, S. Y. Quantum-Confinement and Structural Anisotropy Result in Electrically-Tunable Dirac Cone in Few-Layer Black Phosphorous. *Sci. Rep.* **2015**, 11699.
- (47) Chernikov, A.; van der Zande, A. M.; Hill, H. M.; Rigosi, A. F.; Velauthapillai, A.; Hone, J.; Heinz, T. F. Electrical Tuning of Exciton Binding Energies in Monolayer WS₂. *Phys. Rev. Lett.* **2015**, *115*, 126802.
- (48) Brar, V. W.; Jang, M. S.; Sherrott, M.; Lopez, J. J.; Atwater, H. A. Highly Confined Tunable Mid-Infrared Plasmonics in Graphene Nanoresonators. *Nano Lett.* **2013**, *13*, 2541–2547.
- (49) Wood, J. D.; Wells, S. A.; Jariwala, D.; Chen, K.-S.; Cho, E.; Sangwan, V. K.; Liu, X.; Lauhon, L. J.; Marks, T. J.; Hersam, M. C. Effective Passivation of Exfoliated Black Phosphorus Transistors against Ambient Degradation. *Nano Lett.* **2014**, *14*, 6964–6970.

TOC Graphic:

